

Data Sheet July 1999 File Number 4617.1

# Radiation Hardened Octal Transparent Latch, Three-State

Intersil's Satellite Applications Flow<sup>TM</sup> (SAF) devices are fully tested and guaranteed to 100kRAD total dose. These QML Class T devices are processed to a standard flow intended to meet the cost and shorter lead-time needs of large volume satellite manufacturers, while maintaining a high level of reliability.

The Intersil HCS373T is a Radiation Hardened Octal Transparent Three-State Latch with an active-low output enable. The HCS373T utilizes advanced CMOS/SOS technology. The outputs are transparent to the inputs when the Latch Enable ( $\overline{\text{LE}}$ ) is HIGH. When the Latch Enable ( $\overline{\text{LE}}$ ) goes LOW, the data is latched. The Output Enable ( $\overline{\text{OE}}$ ) controls the three-state outputs. When the Output Enable ( $\overline{\text{OE}}$ ) is HIGH, the outputs are in the high impedance state. The latch operation is independent of the state of the Output Enable.

### **Specifications**

Specifications for Rad Hard QML devices are controlled by the Defense Supply Center in Columbus (DSCC). The SMD numbers listed below must be used when ordering.

**Detailed Electrical Specifications for the HCS373T are contained in SMD 5962-95792.** A "hot-link" is provided from our website for downloading.

www.intersil.com/spacedefense/newsafclasst.asp

Intersil's Quality Management Plan (QM Plan), listing all Class T screening operations, is also available on our website.

www.intersil.com/quality/manuals.asp

## **Ordering Information**

ORDERING NUMBER	PART NUMBER	TEMP. RANGE (°C)
5962R9579201TRC	HCS373DTR	-55 to 125
5962R9579201TXC	HCS373KTR	-55 to 125

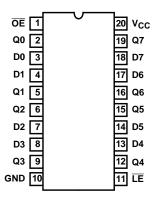
NOTE: Minimum order quantity for -T is 150 units through distribution, or 450 units direct.

#### Features

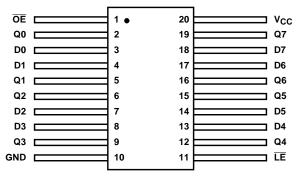
- QML Class T, Per MIL-PRF-38535
- · Radiation Performance
- Gamma Dose (γ) 1 x 10<sup>5</sup> RAD(Si)
- Latch-Up Free Under Any Conditions
- SEP Effective LET No Upsets: >100 MEV-cm<sup>2</sup>/mg
- Single Event Upset (SEU) Immunity < 2 x 10<sup>-9</sup> Errors/Bit-Day (Typ)
- 3 Micron Radiation Hardened CMOS SOS
- Significant Power Reduction Compared to LSTTL ICs
- DC Operating Voltage Range: 4.5V to 5.5V
- · Input Logic Levels
  - $V_{II} = 0.3 V_{CC} Max$
  - $V_{IH} = 0.7 V_{CC} Min$
- Input Current Levels Ii ≤ 5mA at V<sub>OL</sub>, V<sub>OH</sub>

#### **Pinouts**

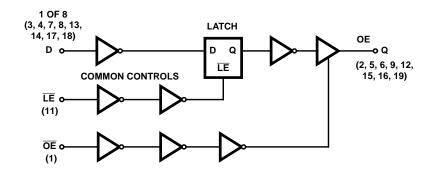
#### HCS373DTR (SBDIP), CDIP2-T20 TOP VIEW



#### HCS373KTR (FLATPACK), CDFP4-F20 TOP VIEW



# Functional Diagram



#### **TRUTH TABLE**

ŌĒ	LE	D	Q
L	Н	Н	Н
L	Н	L	L
L	L	I	L
L	L	h	Н
Н	Х	Х	Z

H = High Level, L = Low Level.

X = Immaterial, Z = High Impedance.

I = Low voltage level prior to the high-to-low latch enable transition.

h = High voltage level prior to the high-to-low latch enable transition.

#### Die Characteristics

**DIE DIMENSIONS:** 

 $(2747 \mu m \ x \ 2693 \mu m \ x \ 533 \mu m \ \pm 51.0 \mu m)$ 

108 x 106 x 21mils ±2mil

**METALLIZATION:** 

Type: Al Si

Thickness: 11kÅ ±1kÅ

SUBSTRATE POTENTIAL:

Unbiased Silicon on Sapphire

**BACKSIDE FINISH:** 

Sapphire

**PASSIVATION:** 

Type: Silox (S<sub>i</sub>O<sub>2</sub>)

Thickness: 13kÅ ±2.6kÅ

WORST CASE CURRENT DENSITY:

< 2.0e5 A/cm<sup>2</sup>

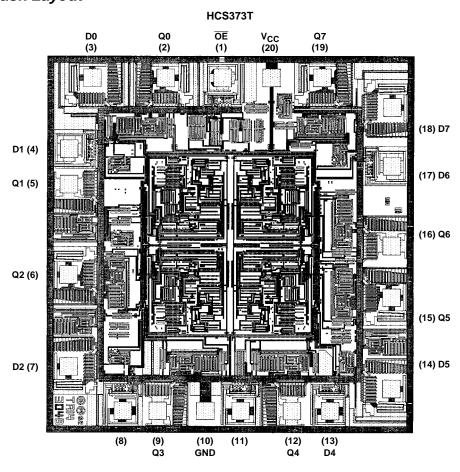
TRANSISTOR COUNT:

376

PROCESS:

**CMOS SOS** 

## Metallization Mask Layout



NOTE: The die diagram is a generic plot from a similar HCS device. It is intended to indicate approximate die size and bond pad location. The mask series for the HCS373 is TA14303A.

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